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CLAIMS

1. A sensor arrangement comprising a substrate, said sensor arrangement having:

a plurality of sensor elements provided as an integrated circuit in the substrate; for each one of the plurality of sensor elements associated electronic circuitry comprising:

- a processing circuit connected to the sensor element,
- an input/output interface connected to the processing circuit; and
 a power supply unit configured to supply operating power only to the
 electronic circuitry associated with one or more of the plurality of sensor elements
 which are in use.
- 2. The sensor arrangement according to claim 1, in which the plurality of sensor elements is distributed over the substrate in a predetermined manner.
- 3. The sensor arrangement according to claim 1, in which the electronic circuitry associated with each one of the plurality of sensor elements is distributed over the substrate in a predetermined manner.
- 4. The sensor arrangement according to claim 1, wherein the sensor is an optical sensor.
- 5. The sensor arrangement according to claim 1, wherein the substrate is configured to fit into a wafer chuck of a lithographic apparatus.
- 6. The sensor arrangement according to claim 1, wherein at least one of the processing circuit, the input/output interface, and the power supply unit is provided as an integrated circuit in the substrate.
- 7. The sensor arrangement according to claim 1, wherein the processing circuit is connected to a memory configured to store at least one among software code and data.

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8. The sensor arrangement according to claim 1, wherein the input/output interface is arranged to exchange data with an external device using a wireless communication technique.

- 9. The sensor arrangement according to claim 1, wherein the sensor arrangement further comprises a chuck on which the sensor arrangement is disposed, the chuck being mountable to a wafer stage of a lithographic apparatus.
- 10. The sensor arrangement according to claim 9, wherein the chuck comprises an interface configured to connect the sensor arrangement to a data network of the lithographic apparatus.
- 11. A sensor arrangement comprising a substrate, said sensor arrangement having:

at least one sensor element provided as an integrated circuit in the substrate; a processing circuit connected to the at least one sensor element; an input/output interface connected to the processing circuit; and

a power supply unit configured to supply operating power to at least one other component of the sensor arrangement, wherein the power supply unit is arranged to convert a wireless signal having a first predetermined frequency into a supply voltage for a first part of the sensor arrangement and to convert wireless energy having a second predetermined frequency into a supply voltage for a second part of the sensor arrangement different from the first part.

- 12. A lithographic apparatus comprising:
- a sensor arrangement comprising a substrate, said sensor arrangement having:
 a plurality of sensor elements provided as an integrated circuit in the substrate;
 for each one of the plurality of sensor elements associated electronic circuitry
 comprising:
 - a processing circuit connected to the sensor element,
 - an input/output interface connected to the processing circuit; and

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a power supply unit configured to supply operating power only to the electronic circuitry associated with one or more of the plurality of sensor elements which are in use.

- 13. The lithographic apparatus according to claim 12, in which the plurality of sensor elements is distributed over the substrate in a predetermined manner.
- 14. The lithographic apparatus according to claim 12, in which the electronic circuitry associated with each one of the plurality of sensor elements is distributed over the substrate in a predetermined manner.
- 15. The lithographic apparatus according to claim 12, wherein the substrate is configured to fit into a wafer chuck of the lithographic apparatus.
- 16. The lithographic apparatus according to claim 12, wherein at least one of the processing circuit, the input/output interface, and the power supply unit is provided as an integrated circuit in the substrate.
- 17. The lithographic apparatus according to claim 12, wherein the processing circuit is connected to a memory configured to store at least one among software code and data.
- 18. The lithographic apparatus according to claim 12, wherein the input/output interface is arranged to exchange data with an external device using a wireless communication technique.
- 19. The lithographic apparatus according to claim 12, wherein the lithographic apparatus further comprises a chuck disposed on a wafer stage of the lithographic apparatus and on which the sensor arrangement is disposed.

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20. The lithographic apparatus according to claim 19, wherein the chuck comprises an interface configured to connect the sensor arrangement to a data network of the lithographic apparatus.

21. A lithographic apparatus comprising:

a sensor arrangement comprising a substrate, said sensor arrangement having:

at least one sensor element provided as an integrated circuit in the substrate; a processing circuit connected to the at least one sensor element; an input/output interface connected to the processing circuit; and

a power supply unit configured to supply operating power to at least one other component of the sensor arrangement, wherein the power supply unit is arranged to convert a wireless signal having a first predetermined frequency into a supply voltage for a first part of the sensor arrangement and to convert wireless energy having a second predetermined frequency into a supply voltage for a second part of the sensor arrangement different from the first part, and

a projection system configured to project a patterned beam of radiation onto a target portion of the substrate;

wherein the sensor arrangement is arranged to measure an aberration of the projection system.

22. A method for measuring properties, such as optical properties, of a device arranged to process substrates, comprising

entering a sensor arrangement in the device and positioning the sensor arrangement in a measurement position;

executing measurements using the sensor arrangement; and removing the sensor arrangement from the device,

wherein the sensor arrangement comprises a substrate, said sensor arrangement having:

a plurality of sensor elements provided as an integrated circuit in the substrate; for each one of the plurality of sensor elements associated electronic circuitry comprising:

- a processing circuit connected to the sensor element,
- an input/output interface connected to the processing circuit; and

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a power supply unit configured to supply operating power only to the electronic circuitry associated with one or more of the plurality of sensor elements which are in use.

- 23. The method according to claim 22, wherein the substrate is configured to fit into a wafer chuck of the device.
- 24. A method for measuring properties, such as optical properties, of a device arranged to process substrates, comprising

entering a sensor arrangement in the device and positioning the sensor arrangement in a measurement position;

executing measurements using the sensor arrangement; and removing the sensor arrangement from the device,

wherein the sensor arrangement comprises a substrate, said sensor arrangement having:at least one sensor element provided as an integrated circuit in the substrate;

a processing circuit connected to the at least one sensor element; an input/output interface connected to the processing circuit; and a power supply unit configured to supply operating power to at least one other component of the sensor arrangement, wherein the power supply unit is arranged to convert a wireless signal having a first predetermined frequency into a supply voltage for a first part of the sensor arrangement and to convert wireless energy having a second predetermined frequency into a supply voltage for a second part of the sensor arrangement different from the first part.